Search Notes			

Application/Control No.	Applicant(s)/Patent under Reexamination	
10/679,822	AGARWAL ET AL.	
Examiner	Art Unit	
W. David Coleman	2823	

SEARCHED				
Class	Subclass	Date	Examiner	
438	300 532 573 685	3/2/2005	WDC	
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INT	INTERFERENCE SEARCHED				
Class	Subclass	Date	Examiner		
438	532	3/2/2005	WDD		
		<del> </del>			

SEARCH NOTES (INCLUDING SEARCH STRATEGY)		
	DATE	EXMR
EAST 2.0.1 Applicants form a difusion barrier to fluorine ions on a gate oxide where the diffusion barrier comprises TiBN	3/2/2005	WDC
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